RESEARCH PAPER

Active frequency-tripler MMICs for 300 GHz signal generation

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Two frequency-tripler monolithic microwave integrated circuits (MMICs) reaching sub-millimeter-wave output frequencies of 315 GHz are presented. The convenient integration of transistor-based field effect transistor (FET) frequency multipliers into multifunctional MMICs is shown by integration of a single-stage frequency-tripler with a buffer amplifier generating -0.5 dBm of peak output power at 288. Without post-amplification an average output power of -10.1 dBm in the output frequency range from 285 to 315 is measured with 10 dBm of input power. The 3-dB bandwidth is more than 30 GHz and could not be determined exactly due to the measurement setup. Both MMICs are realized in a 50 nm meta-morphic high electron mobility transistor (HEMT) transistor technology. A multiple power-meter measurement technique including a waveguide filter is used to measure accurately the second harmonic power content within the output spectrum.

Keywords: Circuit Design and Applications, Modelling, Simulation and characterizations of devices and circuits

Received 14 October 2011; Revised 25 January 2012; first published online 9 March 2012

I. INTRODUCTION

The development of high-speed transistor technologies with increasing f_{max} enables the design of active integrated circuits in the sub-millimeter-wave regions. State-of-the-art high electron mobility transistor (HEMT)-based monolithic microwave integrated circuits (MMICs) are pushing toward higher operating frequencies beyond 300 GHz. In the last few years, active integrated components such as mixers and amplifiers have been demonstrated [1–3]. Higher operating frequencies in radar or imaging applications enable higher image resolution due to the higher available absolute bandwidth and lower wavelength. Also high-speed communication systems will profit from increasing bandwidth with higher possible data rates.

All these components especially mixers and downconverters require signal sources to provide transmit signals or the local oscillator (LO) in frequency mixing applications. The generation can be realized by a phase–locked loop stabilized voltage–controlled oscillator, a fundamental oscillator or by multiplication of a high–quality, low phase-noise lower– frequency signal into the high–millimeter-wave range. In the case of frequency multiplication, the phase-noise will degrade by 20 log (N), where N is the multiplication factor of the frequency multiplier chain [4]. Including the

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Corresponding author: U. J. Lewark Email: ulrich.lewark@kit.edu the noise performance of fundamental sources. A frequency multiplication approach transfers the advantages of lowerfrequency generation such as faster frequency tuning, phase locking, and better phase-noise capabilities into higherfrequency regions. With this signal generation approach, digital synthesized signals could be multiplied into the millimeter-wave range leading to size and cost reduction. Although active frequency multipliers at high frequencies provide less output power as passive approaches, the technology features the possibility of integration with all functional blocks of a radar or communication system into one single MMIC. Providing the LO input at lower frequencies reduces the difficulty of packaging at sub-millimeter-wave frequencies. In terms of module integration, the manufacturing cost and complexity of a waveguide module scale with frequency.

phase-noise degradation a multiplied signal still overcomes

To simplify the 300 GHz generation, a frequency tripler enables input frequencies at W-band (75-110 GHz). This frequency band today is easy to handle and high-quality frequency sources are commercially available for device testing. In this frequency regime integrated frequency multipliers based on metamorphic high electron mobility transistor (mHEMT) transistors are reported in [3, 5, 6], featuring possible frequency-tripler integration with further multiplication stages for 300 GHz millimeter-wave generation from Ku-, X-, or C-band input frequencies [5, 7, 8]. The X-band (8–12 GHz) in particular can provide commercially available solutions for large-scale system integration and direct digital synthesis (DDS) generation for fast frequency tuning. For a metamorphic HEMT doubler, the conversion losses reported in [9] are at least 7.4 dB. Nevertheless, the generation of W-band signals is much easier than 150 GHz signals due to commercially available solutions around the atmospheric window at 94 GHz and the increasing available power at lower frequencies. Therefore, the higher conversion loss is leveraged by easier or cheaper generation of the input signal or the possibility of multifunctional integration.

The major drawback of frequency multiplication is the generation of unwanted harmonics within the output spectrum. These harmonics appear as multiples of the input frequency $\pm n \cdot f_{o}$, where $n \in \mathbb{N}$. Mostly, at very high frequencies the output power is estimated by a total power meter. This measurement method integrates all harmonic powers of the output spectrum, hiding spurious responses within the output signal. In the doubler case, the fundamental tone will be suppressed by the waveguide cut-off but at higher multiplication factors the output signal contents several spurious lines. Based on the experimental results presented in [10], we show measurements of the second harmonic power in H-band (220-325 GHz). In this frequency range mixers cannot be reliably calibrated. Therefore, the second harmonic power is calculated from a combination of two total power meter measurements using a waveguide high-pass filter.

II. METAMORPHIC HEMT TECHNOLOGY

For high-frequency and low-noise applications, the Fraunhofer Institute for Applied Solid State Physics (IAF) has developed a mHEMT technology with a gate length of 50 nm [6, 11]. The transistor is based on an InGaAs/InAlAs heterostructure with high in content. For lower cost and quality, the HEMT structure is grown on 4" semi-insulating GaAs wafers. For the metamorphic buffer, a linear In_xAl_y Ga_{1-x}As ($x = 0 \rightarrow 0.52$) transition is used. The electrons are confined in an In_{0.80} Ga_{0.20} As/In_{0.53} Ga_{0.47} As composite channel, improving the breakdown behavior of the device. For high f_{max} values and low-noise figure, a low gate line resistance is needed. Therefore, the *T*-gate uses a Pt/Ti/Pt/ Au metallization.

For interconnects, an Au layer and a $2.7-\mu$ m-thick plated Au-layer in air-bridge technology are used. Further passive elements are NiCr thin-film resistors and MIM capacitors formed by the two metal layers and the SiN passivation as the dielectric layer. For the realization of MMICs operating at high millimeter-wave frequencies, a full backside process including wafer thinning to a final thickness of 50 μ m was developed for the suppression of parasitic substrate modes. Through-substrate vias are etched with a diameter of 20 μ m. Due to the high selectivity of the etching process the placement of the vias below MIM capacitors is possible.

The f_t and f_{max} values are extrapolated for a passivated mHEMT with $2 \times 15 \,\mu$ m gate width. An overview of the electrical DC and RF parameters is given in Table 1.

III. CIRCUIT DESIGN

Frequency multiplication conventionally is done by driving a non-linear device that converts the input power into a multiharmonic signal. This device usually is a diode. Diodes are used up to the THz regime for frequency generation together with very high conversion losses and high integration cost. In this approach, the non-linear device is a FET amplifier stage under large-signal conditions. The choice of the generation

Table 1.	50 nm mHEMT DC and RF	
	parameters.	

In content	80%
R_s	0.15 Ωmm
I _{D,max}	1200 mA/mm
V _{BD,on-state}	1.5 V
V _{BD,off-state}	2.5 V
$V_{\rm th}$	-0.25 V
gm,max	1800 mS/mm
\mathbf{f}_t	375 GHz
f_{max}	375 GHz
MTTF	2.7×10^{6} h

type thereby plays an important role. There are two ways to generate harmonic output power with an amplifier stage. Most common is biasing the circuit under class AB or lower condition resulting in cutting parts of the sinusoidal input signal. For a frequency doubler the best bias condition is class B, creating a half-sinusoidal output waveform mainly consisting of even-order harmonics. The odd-order harmonic current at the drain is short-circuited by a $\lambda/4$ stub at the fundamental frequency. In and output have to be matched at the fundamental and the wanted harmonic frequency. Odd-order frequency generation also is possible by using a class A amplifier stage driven into deep saturation or under deep class B bias [12]. The sinusoidal input drive then is transformed into a trapezoidal waveform rich of odd-order harmonics [4]. The major drawback is the needed high input power drive and therefore high conversion loss, which gets worse with increasing multiplication factor N. Another problem of a class A-type active frequency multiplier is the device gain at the fundamental tone. Short circuiting the fundamental current at the output leads to reflection of the amplified input signal. Either the input circuit has to be designed with a resistor for attenuating the reflected signal or the output matching needs a sink for the fundamental current. High reflection of the fundamental tone at the output of the circuit leads to an unwanted positive input reflection coefficient S₁₁ and high risk of oscillation. At high frequencies, this effect gains importance due to the high influence of the parasitic gate drain capacitance. In the case of frequency tripling, we decided to use a common source FET amplifier stage under compressed class A operation. The first design step after choosing the basic circuit type is the device size. At very high frequencies a large gate width leads to high parasitic input capacitance but can handle more drain current and is able to deliver more output power. On the other side a high output power at this multiplier type leads to very high input power constraints. Therefore, the choice of the gate width is a trade-off between available output power and a low compression point. Very high input powers can lead to device damage by introducing a parasitic gate current up to mA scale, reducing dramatically the circuit lifetime and reliability. Based on advanced design system (ADS) simulations with the IAF large-signal transistor models a two finger device with a total gate width of $2 \times 15 \,\mu\text{m}$ is used for optimum conversion performance at 100 GHz with a realistic available input power of 10 dBm at the input.

The input of the amplifier FET is matched to 50Ω at the input frequency f_0 (IMN), while the output matching network (OMN) is providing conjugate complex matching at the third harmonic $3f_0$. After that a band-pass filter (BPF)



Fig. 1. Schematics of the 300 GHz triplers, both based on a single mHEMT amplifier under compressed class A conditions.

suppresses all unwanted harmonics at the output of the circuit. Figure 1 shows the frequency-tripler schematic. The input network is a bias-T, connecting the gate voltage V_G to the transistor gate. (TRL) l_1 works as a shorted stub, RF grounded by \tilde{C}_b . Within the OMN, the fundamental and second harmonic are reflected by either the BPF or by the very small series capacitor COUT, building up a high-passtype bias-T connecting the drain voltage. The resistor R suppresses the reflections and stabilizes the circuit representing a 50 Ω load for the fundamental tone. Without the resistor the reflected power leads to oscillations of the circuit due to the feedback of the parasitic gate drain capacitance of the common source mHEMT at high frequencies. This topology already is known from microwave frequency-tripler designs reported in [4]. The loss introduced by the resistive load is reduced by a combination of two $\lambda/4$ transitions at the third harmonic. TRL l_2 converts an open circuit to a short circuit and, via TRL l_3 , back to an open circuit at $3f_0$. As the two $\lambda/4$ transitions represent an open circuit, the impedance still needs to be matched by l_{4} and C_{OUT} to 50 Ω .

The major filter stage is a coupled-lines-type filter. Starting values for field simulation in Ansoft's HFSS are found using simplified ADS coupled lines models. The distance to the electrical ground and the width of the coupled lines are optimized for impedance match to 50Ω at the filter terminals for 300 GHz. Also the losses of the coupler have to be kept low for optimal conversion efficiency. Therefore, the conductor gap is optimized for minimal loss and adequate suppression at $2 f_0$ and f_0 .

Figure 2 shows a chip photograph of the frequency tripler MMIC. Its total chip size is 0.5 \times 0.75 mm², including RF and DC Pads. The grounded coplanar waveguide transmission lines have a reduced ground-to-ground spacing of 14 μ m tapered at the RF pads.

Besides this chip, a slightly different version of the frequency tripler MMIC was processed. The circuit schematic is shown in Fig. 1(b). In this version the double $\lambda/4$ stub construction is replaced by a stub filter at the second harmonic (l_2) and a shorted stub-type transforming bias-T (l_3, C_{OUT}) . To encounter the introduced reflections from the output, the input network has to transform a much lower input impedance and therefore has longertransmission lines. The tripler operates with a compressed class A FET stage driven into input power saturation.

Showing the benefits of an active frequency multiplier concept the tripler is followed by a two-stage cascode amplifier with 10 dB gain in one single MMIC. Figure 3 shows the chip photograph of the integrated frequency multiplier. The total chip size of 1.25×0.5 mm² is small enough for convenient integration into circuits with higher integration level within the Fraunhofer IAF's 50 nm mHEMT technology



Fig. 2. Chip photograph of the 300 GHz frequency-tripler realized in 50 nm mHEMT technology. The total chip size including DC and RF pads is 0.5 \times 0.75 mm².

and represents a power source to drive sub-millimeter-wave mixers around 300 GHz with a W-band input.

IV. MEASUREMENT SETUP AND EXPERIMENTAL RESULTS

For the multiplier MMIC characterization on-wafer measurements are carried out comprising careful power–level normalization. Since the input and output power levels have to be normalized to the probe tip, the losses of the coplanar measurement probes in WR-3 band are defined using two WR-3 frequency extensions to a standard network analyzer. The input signal is generated with a commercial W-band source module extended by an in-house power amplifier, generating 10 dBm of input power from 95–105 GHz at the probe tip. Output power is measured by a total power meter (calorimeter). The most critical unwanted signal is the fundamental tone, which is suppressed totally by the WR-3 waveguide cut-off. Figure 4 sketches the characterization setup of the frequency tripler.

Assuming the conversion into higher tones than the third harmonic is negligible, the second harmonic may still be present within the WR-3 waveguide. For proving the presence of the third harmonic a waveguide type high-pass filter is



Fig. 3. Chip photograph of the frequency-tripler MMIC integrated with an output buffer. The total chip size is 1.25 × 0.5 mm².



Fig. 4. On-wafer measurement setup for the 300 GHz frequency tripler. The power meter can be connected either directly or with a high-pass (HPF) filter to the WR-3 probe.

introduced into the measurement setup. By estimating the total power with (P_{filt}) and without (P_{tot}) the filter, the power of the second harmonic P_2 can easily be calculated by taking the linear difference:

$$P_{2} = 10 \log \left(10^{\frac{P_{tot}}{10}} - 10^{\frac{P_{filt}}{10}} \right).$$
 (1)

A) Stand-alone frequency tripler MMIC

A sweep of the input power at 100 GHz from 0 to 10 dBm reveals a saturated output power of -10.6 dBm at 300 GHz as shown in Fig. 5. At 10 dBm of input power, the circuit shows a conversion gain of -20.6 dB. Previous odd-order frequency multipliers with compressed class A transistor devices in [7] showed best output performance several dBs over the compression point, when the output signal turns more and more into a trapezoidal waveform. In the experiment shown in Fig. 5, this point is not reached, predicting higher available output power combined with higher conversion loss. The normalization of the input power takes into account the compression of the input power amplifier, therefore no more power could be applied and the measured saturation belongs to the device under test. At an input power of 4 dBm the conversion gain reaches its maximum of - 18.5 dB, i.e. a conversion efficiency of 1.4%.

Figure 6 shows the saturated output power versus input frequency for a constant input power level of 10 dBm. For proving the presence of the third harmonic two measurements have been taken. The first measurement without a WR-3 waveguide high-pass filter (black) reveals the saturated total output power of the chip. Unfortunately, the total power meter can only measure the sum of all harmonic power within the output spectrum. A second measurement canceling



Fig. 5. Third harmonic output power at 300 GHz versus input power at 100 GHz (fundamental). The frequency tripler achieves a saturated output power of -10.6 dBm and a conversion gain of -18.5 dB.



Fig. 6. Measured harmonic output power versus input frequency demonstrates a bandwidth of at least 285-315 GHz. The output power reaches its maximum at 303 GHz with -11.2 dBm.

out the second harmonic power (red) by the high-pass filter shows a loss of 2 dB of output power around 300 GHz. This can be explained by a rising presence of the second harmonic in this frequency region. The calculated power of the second harmonic is also shown as the blue curve. The harmonic

suppression is only adequate in the frequency regions where the two measurements show almost no difference. Around 300 GHz the suppression is only 3 dB, meaning that the second harmonic is present with half the power of the third. At lower and higher frequencies the suppression gets better than 10 dBc. The circuit presents a measured bandwidth of 285-315 GHz while the 3-dB bandwidth could not be measured due to the limited bandwidth of the power amplifier at the input of the measurement setup. The measured bandwidth already shows a relative bandwidth of at least 10%, i.e. an absolute bandwidth of 30 GHz. The input frequency sweep also reveals a maximum output power of -11.2 dBm and a sufficient suppression of unwanted harmonics below 288 and above 312 GHz. The comparison of the measured results and harmonic balance simulations (dashed lines) shows very good performance of the underlying large-signal models [13]. While the output power of the third harmonic is predicted correctly, the observed rising of the second harmonic power content was not predicted.

Since the total bandwidth of the frequency tripler could not been measured due to the input power constraints, only a small part of the simulated bandwidth could be verified. Figure 7 shows a large-signal S-parameter simulation of the measured circuit. Large-signal S-parameters are normalized to the input frequency and are showing input matching at the fundamental (S_{11}) and output matching at the third harmonic (S_{22}) . The gain (S_{21}) represents the conversion gain of the tripler. Comparing the measured gain and the simulated S_{21} also shows a very good agreement between simulation and measurement. The simulated 3-dB bandwidth corresponds with large signal output matching and is simulated from 250 to 360 GHz, i.e. a relative bandwidth of 36%. The center frequency is 305 GHz.

The frequency multiplier MMIC is fed by a single 1.2 V drain supply together with class A gate bias. At 10 dBm input power at an input frequency of 100 GHz, the MMIC consumes 14.4 mW (I = 12 mA) of DC power. Low DC power consumption and small chip size are important for further monolithic integration with other functional blocks of a system, such as mixers and amplifiers. At increasing input power level the FET gate diode starts to draw gate current. At further design steps the gate should be protected by a small resistance and within an application the device

should not be driven into deep saturation. A parasitic gate current flow decreases the mean time to failure (MTTF) and degrades the device.

B) Buffered frequency-tripler MMIC

For the integrated tripler MMIC with buffer amplifier, a sweep of the input power at 288 and 300 GHz in Fig. 8 shows only a slight saturation behavior. At 12 dBm of input power, the output power still rises with 0.5 dB per dB of input power. Not compressing the amplification stage is very important because the amplifier used in this MMIC also has gain at second harmonic frequencies. Compressing it at third harmonic frequencies leads to lower suppression without significant gain of output power for the third harmonic content. Nevertheless in further designs a specially designed amplifier stage would be able to suppress the strong second harmonic signal around 300 GHz. Due to the gain of the amplifier the total conversion loss of the chip is reduced to a maximum of -11.4 dB at an input power of 5 dBm and an input frequency of 96 GHz. Like in the previous version, the conversion into the third harmonic is less efficient at 100 GHz input. At this frequency a significant part of the input power is transferred into the second harmonic.

Comparing the sweep of the input power versus the output power of the stand-alone tripler and buffered tripler MMICs in Fig. 9 shows a power gain of 10.3 dB. At 6 dBm the amplifier gain decreases while the output power of the stand-alone tripler operates without significant saturation behavior. For this measurement the input power amplifier of the test setup could provide 16 dBm of power at the probe tip. At 16 dBm the tripler MMIC reaches saturation and shows a maximum output power of -7 dB without post-amplification. The integrated MMIC with output buffer provides 6.5 dB of gain and -0.5 dBm of output power providing a 0.9 mW sub-millimeter-wave power source.

At 288 GHz output frequency the MMIC generates a saturated output power of -0.5 dBm for an input power of 14 dBm (Fig. 10). The average output power is -1.9 dBm in the output frequency range from 285 to 315 GHz. For comparison with the stand-alone frequency-tripler, the output power of the amplified frequency-tripler is plotted with the same input power of 10 dBm (black). The frequency-tripler version implemented in the integrated version also has been



Fig. 7. Large signal S-parameter simulation results of the $_{300}$ GHz tripler compared with the measured conversion gain (S $_{_{21}}$).



Fig. 8. Measured harmonic output power versus input power of the buffered frequency tripler MMIC.



Fig. 9. Output power versus input power of amplified and stand-alone frequency tripler MMIC. The output power reaches -0.5 dBm at 300 GHz.



Fig. 10. Measured harmonic output power versus input frequency of both, amplified and stand-alone frequency-tripler MMICs.

characterized using the filter power measurement method revealing a small difference around 300 GHz (red). The result is shown in Fig. 10 including the calculated second harmonic content. Comparing the power levels of the stand-alone MMIC with the buffer MMIC the measurements reveal more than 11 dB of power gain by the two-stage buffer amplifier.

The MMIC is fed by a 2 V drain and 1.2 V cascode and tripler drain supply together with class A gate bias. At 10 dBm input power and an input frequency of 100 GHz, the MMIC consumes 64 mW of DC power.

V. STATE-OF-THE-ART FREQUENCY MULTIPLICATION AROUND 300 GHZ

Since fundamental frequency generation around 300 GHz is suffering from low bandwidth and frequency stability only multipliers in different technologies are shown in Table 2. The highest output power is demonstrated with a passive heterostructure barrier varactor (HBV) drawing very high input drives of 1 W around 150 GHz together with high integration and packaging cost of diode technologies. Silicon bipolar technologies may have advantages in integration level but do not reach the band–width and low–noise operation of In-channel–based technologies. Therefore, silicon–based LO sources cannot overcome the packaging cost reduction and simplification together with a high–performing LNA.

Although the losses are high due to the ineffective conversion into odd-order harmonics with FETs [4, 12], the fast IAF mHEMT technology enables on chip amplifier integration. 13.5 dB of gain has been demonstrated at 300 GHz in [2], respectively. The active approach of frequency multiplication, combined with ultra fast transistors, enables the integration with output buffer amplifiers on chip level even at sub-millimeter-wave output frequencies. Besides amplifier integration, more functionality can be integrated. The proof of this concept is an even higher integrated MMIC also including the presented tripler circuit. The on-chip buffer amplifier provides enough power for LO power generation around 300 GHz. The circuit in [14] is an integrated down-conversion mixer with RF low-noise amplifier, while the LO of the fundamental mixer is provided by the presented buffered tripler MMIC. In this highly integrated MMIC the advantages of active frequency tripling result in a 300 GHz receiver with cost reducing W-band LO input together with the state-of-the-art low-noise performance of In-based HEMT low-noise amplifiers within the sub-millimeter wave regime.

VI. CONCLUSION

With the presented tripler MMIC frequency multiplication from W-band into H-band was demonstrated, enabling sub-millimeter-wave generation by easy to handle W-band signals. The realized tripler delivers -7 dBm of peak output power in a measured tuning range of at least 30 GHz within 285 and 315 GHz, whereas the 3-dB bandwidth could not be determined experimentally. Integrated with an output buffer amplifier, the presented frequency tripler shows an average output power of -1.9 dBm between 285 and 315 GHz and a peak output power of -0.5 dBm at 300 GHz. Power measurements with a waveguide filter are revealing the presence and power level of the second harmonic

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Reference	BW in GHz	Ν	Av. P _{out} in dBm	DC Power in mW	Chipsize in mm ²	Technology
[15]	352-388	2	7			Schottky HBV
[9]	250-310	2	-9.5		0.50×0.75	InGaAs mHEMT
[3]	300	3	-3			InP HEMT
[16]	317-328	18	-9	1217.8	2.20×0.43	SiGe heterojunction bipolar transistor (HBT)
This work	285-315	3	-10.1	14.4	0.50×0.75	InGaAs mHEMT
This work	285-315	3	-1.9	64	1.25×0.50	InGaAs mHEMT

within the WR-3 waveguide. The benefits of an active multiplier approach are shown by the presented integrated MMIC.

ACKNOWLEDGEMENTS

We express our gratitude to our colleagues at IAF for their excellent contributions during epitaxial growth and wafer processing. We are particularly indebted to Michael Schlechtweg and Oliver Ambacher for their continuous support throughout this work.

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